

Figure Captions

Fig. S1. The work function (W) determined by the difference between the photo energy and the binding energy of the secondary cutoff edge. ($W = 21.2 \text{ eV} - 16.6 \text{ eV} = 4.6 \text{ eV}$)

Fig. S2. (a) Typical C-V curve of 3D Ni/NiO/MoS₂ foam with continuous addition of DA under continuous agitation. (b) Typical C-V curve of rGO with continuous addition of DA under continuous agitation.

The scan range is from -0.6V to 0.6V at a rate of $100 \text{ mV}\cdot\text{S}^{-1}$ and the number of sweep segments is 4.

Fig. S3. (a) The electrochemical response of the single MoS₂ to 1 mM DA, UA and AA in 0.01 M PBS at pH = 7.4. (b) The electrochemical response of the single rGO to 1 mM DA, UA and AA in 0.01 M PBS at pH = 7.4. The scan range is from -0.6V to 0.6V at a rate of $100 \text{ mV}\cdot\text{S}^{-1}$ and the number of sweep segments is 4.

Fig. S4. CV curves of Ni/NiO (a), Ni/NiO/MoS₂ (b), and Ni/NiO/MoS₂/rGO (c) against different scan rates.

Annotation: The the actual electrochemically active surface area was performed at room temperature in 0.1 M PBS (pH 7.4) using a standard three-electrode cell, where a Ag/AgCl electrode served as the reference electrode, a Pt wire served as the counter electrode, and the Ni/NiO or Ni/NiO/MoS₂ or Ni/NiO/MoS₂/rGO (typically $1\times 1.5 \text{ cm}^2$) covered with products served as the working electrode. All potentials were measured against the Ag/AgCl electrode and converted to the reversible hydrogen electrode (RHE) reference scale using $ERHE \text{ (V)} = E_{\text{Ag/AgCl}} + 0.197 + 0.059 \times \text{pH}$. Cyclic voltammetry was measured from 0 to 0.1 V vs RHE at different scan rates from $20 \text{ mV}\cdot\text{s}^{-1}$ to $200 \text{ mV}\cdot\text{s}^{-1}$.

Fig. S5. Nyquist plots of EIS of the Ni/NiO (a), the Ni/NiO/MoS₂ (b) and the Ni/NiO/MoS₂/rGO (c) with the addition of $3 \mu\text{M}$ DA in the frequency ranges from 0.01 Hz to 100 KHz.

Fig. S6. Reproducibility of 3D Ni/NiO/MoS₂/rGO foam after 100 successive cyclic voltammograms measurement for 1 mM DA.

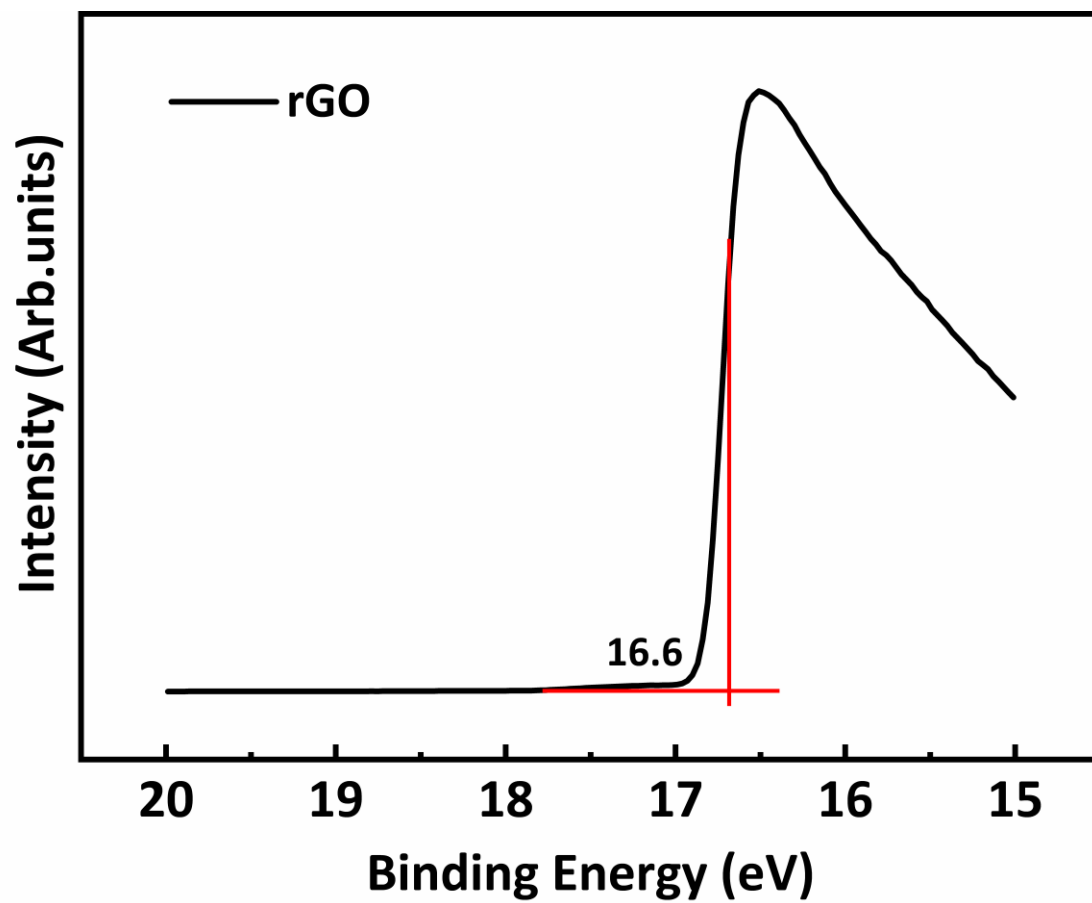


Fig.S1

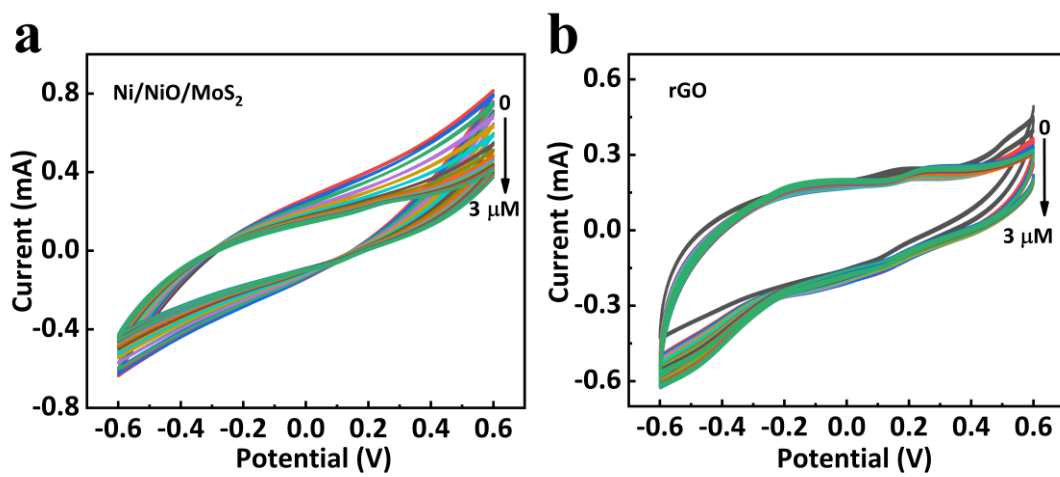


Fig.S2

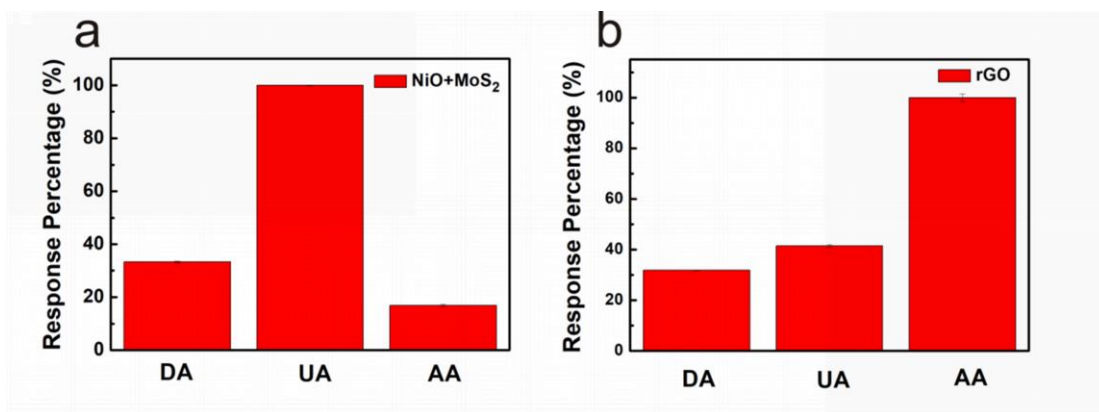


Fig.S3

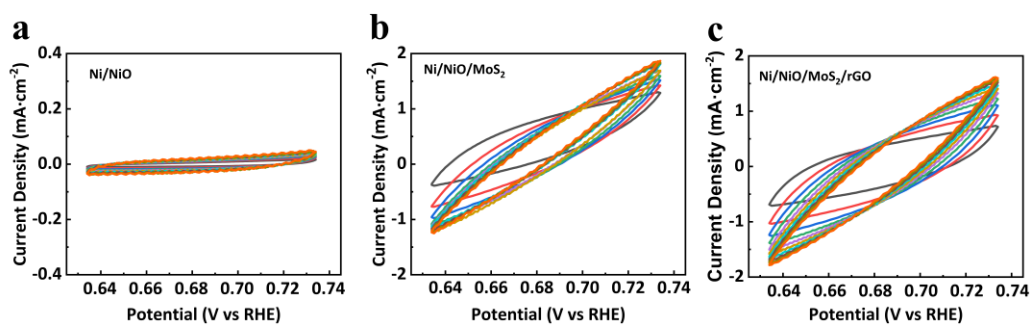


Fig.S4

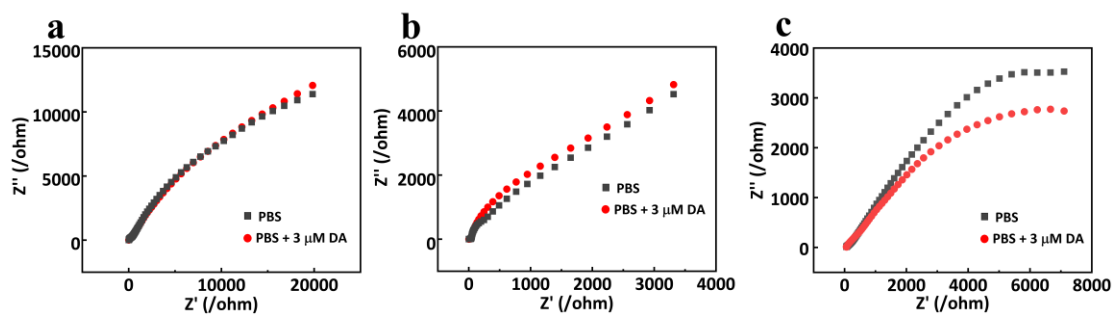


Fig.S5

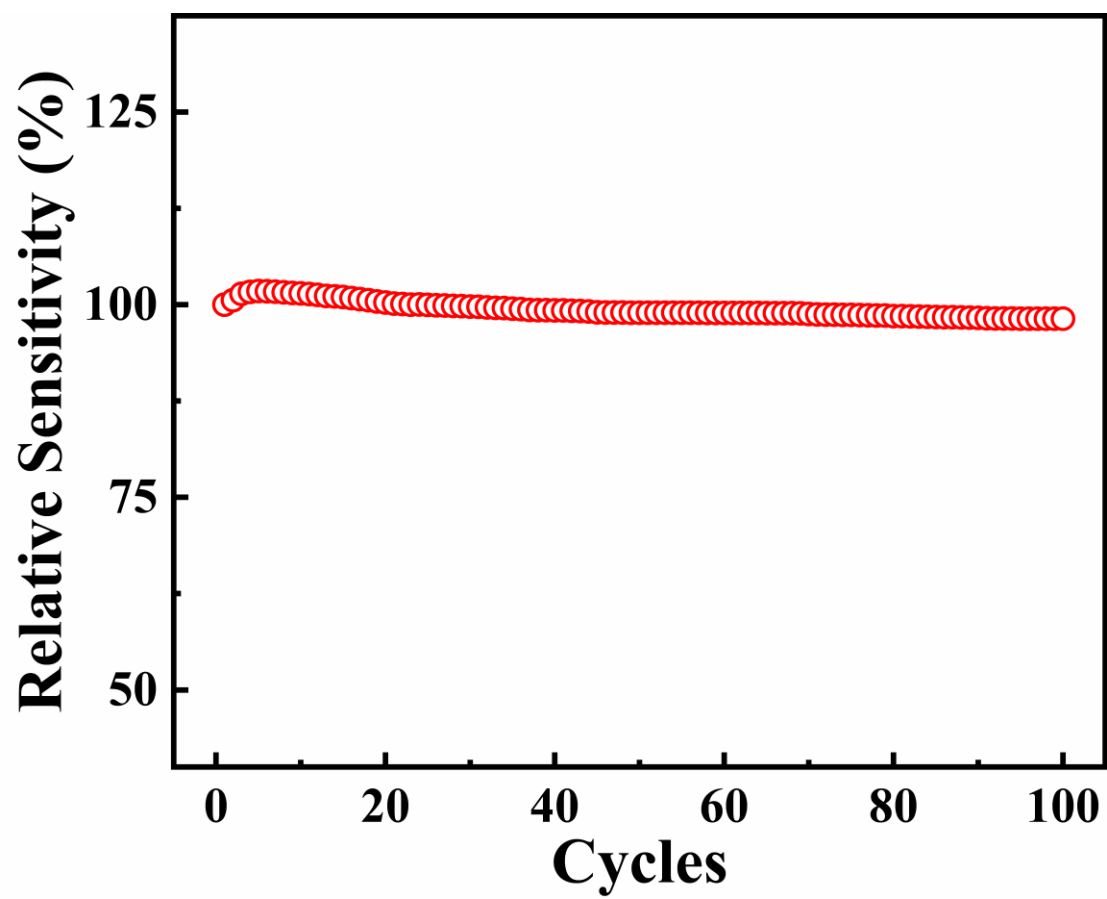


Fig. S6